

# Test Capabilities



- **8 On-wafer Auto Probe Stations**

- 5 Electroglas 2001X auto probers
- 2 Cascade Microtech Probers
- 1 Karl Suss Prober

- **5 RF test and Characterization systems**

- Wafer level production OIP3 testing
- HP8722D Network Analyzer/ICCAP (.05 – 40 GHz): Insertion and return loss, Isolation, s-parameters, DC parameters, device modeling
- HP8510C Network Analyzer (.01 – 26.5 GHz): Insertion and return loss, isolation s-parameters, device model
- Maury Microwave (0.8 – 18 GHz): Source/load pull, noise parameters, IP3, harmonics, ruggedness
- Focus Tuners (6 – 40 GHz): Source/load pull, noise parameters, IP3, harmonics, ruggedness

- **3 DC test systems**

- PCM and 100% on-wafer die testing



# Electroglas On-wafer Characterization Probe Station

- Electroglas 2001X Automatic Probe Station
- HP Network Analyzer 8510C (10 MHz – 26.5 GHz)
- HP Synthesized Sweeper 83631B
- Test capabilities include:
  - S parameters measurements (insertion loss, return loss, isolation, etc.)
  - Small signal modeling
  - Large signal modeling



# On-Wafer Automated Test Systems



## Two Production On-Wafer Automated Test Stations

- ReedHolm Semiconductor Parametric Tester and ElectroGlas Automated Probe Station
- High-speed PCM tests include device DC parameters, material and process parameters
- High-speed DC testing for product die screening
- Test speed: 10 ms per parameter, 0.1 sec per die stepping



# 100% Die Test and Inking Capability



## WCDMA PA

# Parameters	37
# Total Dies	4950
# Fails	115
# Passes	4835
Die Yield	97.7%

